

	Hits	Search Text	DBs
2	1	((photoreact\$4 or photo\$3cur\$5 or photosensitive or photoactiv\$5) same (silane or ((oligomer\$3 or polymer\$5) near8 (silicon or Si or silane))) same (expos\$4 or irradiat\$4 or illuminat\$4) same pattern\$4) and ((photoreact\$4 or photo\$3cur\$5 or photosensitive or photoactiv\$5) same photoinitiat\$4) and ((multi\$4 near9 photon) or (electron near8 (accept\$4 or don\$5))))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
3	0	((photoreact\$4 or photo\$3cur\$5 or photosensitive or photoactiv\$5) same (silane or ((oligomer\$3 or polymer\$5) near8 (silicon or Si or silane))) same (expos\$4 or irradiat\$4 or illuminat\$4) same pattern\$4) and ((photoreact\$4 or photo\$3cur\$5 or photosensitive or photoactiv\$5) same photoinitiat\$4) and (interference or (multi\$4beam near6 interference))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
4	0	((photoreact\$4 or photo\$3cur\$5 or photosensitive or photoactiv\$5) same (silane or ((oligomer\$3 or polymer\$5) near8 (silicon or Si or silane))) same (expos\$4 or irradiat\$4 or illuminat\$4) same pattern\$4) and photoinitiat\$4 and (interference or (multi\$4beam near6 interference))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
5	8	((photoreact\$4 or photo\$3cur\$5 or photosensitive or photoactiv\$5) same (silane or ((oligomer\$3 or polymer\$5) near8 (silicon or Si or silane))) same (expos\$4 or irradiat\$4 or illuminat\$4)) and photoinitiat\$4 and (interference or (multi\$4beam near6 interference))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
6	3	((("6569602") or ("5526449") or ("200200062782") or ("200200160298") or ("6358653"))).PN.	US-PGPUB; USPAT
7	5	((("6569602") or ("5526449") or ("20020062782") or ("20020160298") or ("6358653"))).PN.	US-PGPUB; USPAT
8	98	(multi near9 photosens\$9) and rhodamine	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
9	1	(multi near9 photosens\$9) and rhodamine and (photonic near9 crystal)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
10	2	(multi near9 photosens\$9) and rhodamine and optoelectronic	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
11	26	(multi near9 photosens\$9) and optoelectronic	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
12	5	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same ((multi\$4 or two or four or plural\$4 or three) near8 (photon or beam))) and (expos\$4 or irradiat\$4 or illuminat\$4) and (etch\$4 or remov\$4) and interference and (donor or acceptor or (electron near8 accept\$5) or (electron near8 don\$5)) and cur\$4 and (sol\$3gel or ((polymer\$5 or oligomer\$5) near14 (silane or siloxane or silicon or Si))) and (photoinitiat\$4 or (radical near9 initia\$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
13	6	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same (inorganic or (metal\$3 near8 oxide) or alumina or titanium near5 oxide or titania or Zirconia or silica or vanadia)) and ((multi\$4 or two or four or plural\$4 or three) near8 (photon or beam)) and (expos\$4 or irradiat\$4 or illuminat\$4) and (etch\$4 or remov\$4) and interference and (donor or acceptor or (electron near8 accept\$5) or (electron near8 don\$5)) and cur\$4 and (sol\$3gel or ((polymer\$5 or oligomer\$5) near14 (silane or siloxane or silicon or Si))) and (photoinitiat\$4 or (radical near9 initia\$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB